

Hafnium Carbide (HfC) Sputtering Targets

Material Type	Hafnium Carbide	Theoretical Density (g/cc)	12.2
Symbol	HfC	Z Ratio	**1.00
Melting Point (°C)	~3,890	Sputter	RF
Purity:	99.9%, 99.95%	Type of Bond	Indium